

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

<b>Applicant(s):</b>	William G. America, et al.	<b>Examiner:</b>	Jack S. J. Chen
<b>Serial No:</b>	10/674,646	<b>Art Unit:</b>	2813
<b>Filed:</b>	September 30, 2003	<b>Docket:</b>	YOR920030320US1 (16868)
<b>For:</b>	PLASMA SURFACE MODIFICATION AND PASSIVATION OF ORGANO- SILICATE GLASS FILMS FOR IMPROVED HARDMASK ADHESION AND OPTIMAL RIE PROCESSING	<b>Dated:</b>	June 29, 2007

*Enter with  
RCE 8-6-07*

**Confirmation No.** 4797

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**RESPONSE UNDER 37 C.F.R. § 1.116**

Sir:

In response to the Final Office Action dated April 4, 2007, and in accordance with the provisions of 37 C.F.R. §1.116, Applicants submit the following remarks for entry in the above-identified case.

**CERTIFICATE OF ELECTRONIC FILING**

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website.

Dated: June 29, 2007

  
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Leslie S. Szivos, Ph.D.